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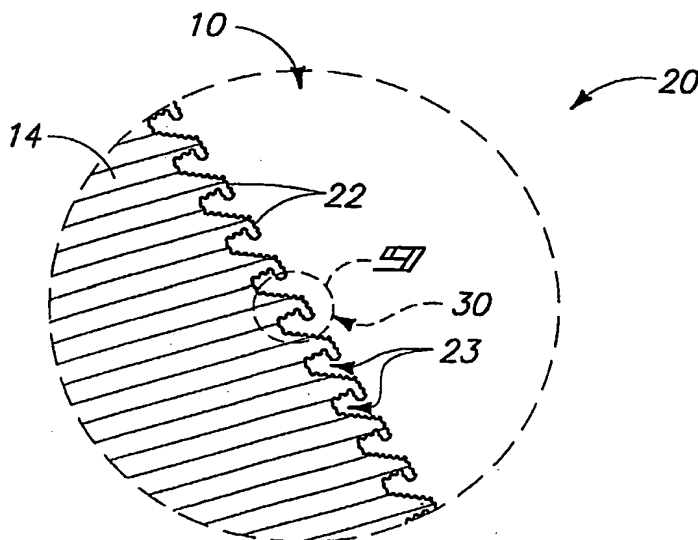
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(54) Title: METHODS OF TREATING COMPONENTS OF A DEPOSITION APPARATUS TO FORM PARTICLE TRAPS, AND
SUCH COMPONENTS HAVING PARTICLE TRAPS THEREON



(57) Abstract: The invention includes methods
for forming particle traps along surfaces of PVD
components, and comprises PVD components
having particle traps thereon. The invention
can include utilization of highly soluble media
for bead-blasting and/or can include utilization
of metallic materials as bead-blasting media.
The invention can also include formation of an
insert along regions of a backing plate where
particle traps are desired, with the insert being of
a composition which has better particle-trapping
properties than the backing plate.

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